

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
9 June 2005 (09.06.2005)

PCT

(10) International Publication Number
WO 2005/051845 A3

(51) International Patent Classification:
COIF 7/34 (2006.01) *COIF 7/44* (2006.01)

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(21) International Application Number:
PCT/EP2004/0 13226

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(22) International Filing Date:
19 November 2004 (19.11.2004)

(81) Designated States (*unless otherwise indicated, for every kind of national protection available*): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:
60/524,875 26 November 2003 (26.11.2003) US
03078996.0 19 December 2003 (19.12.2003) EP

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(84) Designated States (*unless otherwise indicated, for every kind of regional protection available*): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

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Published:

— with international search report
— before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments

(88) Date of publication of the international search report:
15 June 2006

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: HYDROTHERMAL PROCESS FOR THE PREPARATION OF QUASI-CRYSTALLINE BOEHMITE

(57) Abstract: Process for the preparation of quasi-crystalline boehmite comprising the steps of: (a) preparing an aqueous precursor mixture comprising a water-insoluble aluminium source; (b) decreasing the pH of the precursor mixture of step (a) by at least 2 units; (c) increasing the pH of the mixture of step (b) by at least 2 units, and (d) aging the mixture of step (c) under hydrothermal conditions to form a quasi-crystalline boehmite. This process provides for the hydrothermal preparation of quasi-crystalline boehmites with high peptizability. The invention therefore further relates to quasi-crystalline boehmites with a high peptizability, measured as the Z-average submicron particle size. This Z-average submicron particle size preferably is less than 500 nm, more preferably less than 300 nm, even more preferably less than 200 nm, and most preferably less than 100 nm.



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